

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:

Lutz ASCHKE et al.

Group Art Unit 1756

Serial No.: 10/825,618

Examiner: ROSASCO, Stephen D.

Filed: April 16, 2004

For: MASK BLANK FOR USE IN EUV LITHOGRAPHY AND METHOD FOR ITS PRODUCTION

**AMENDMENT UNDER 37 CFR 1.312**

Mail Stop: Issue Fee  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

SIR:

Please amend the claims as follows and consider the remarks.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 7 of this paper.